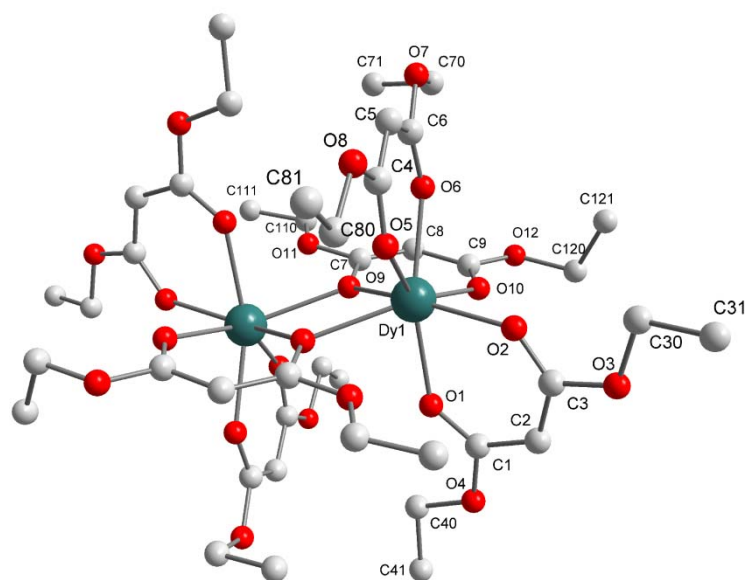
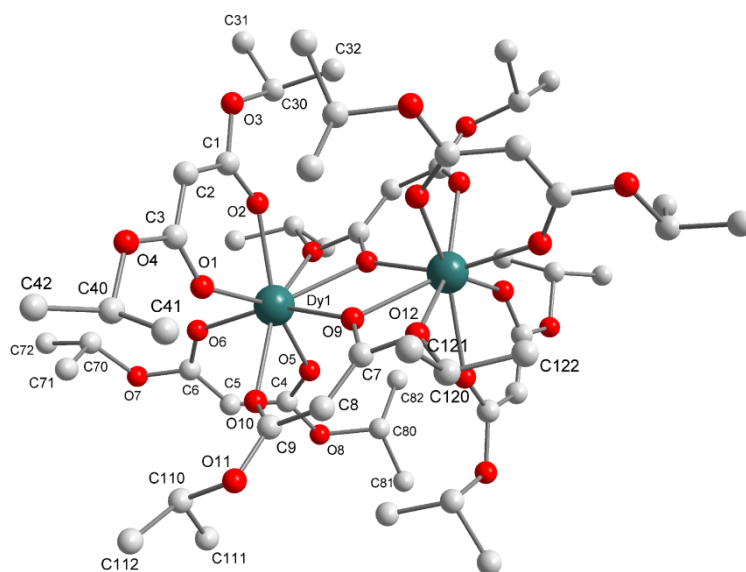


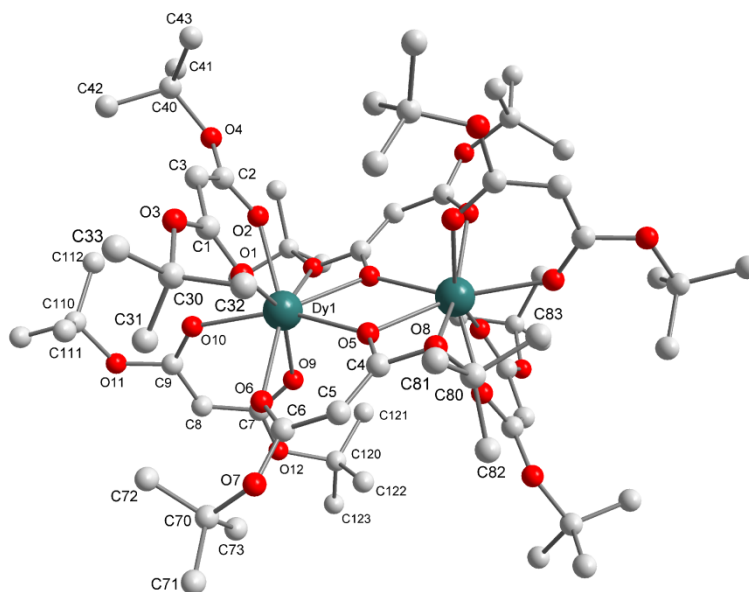
## Supporting Information



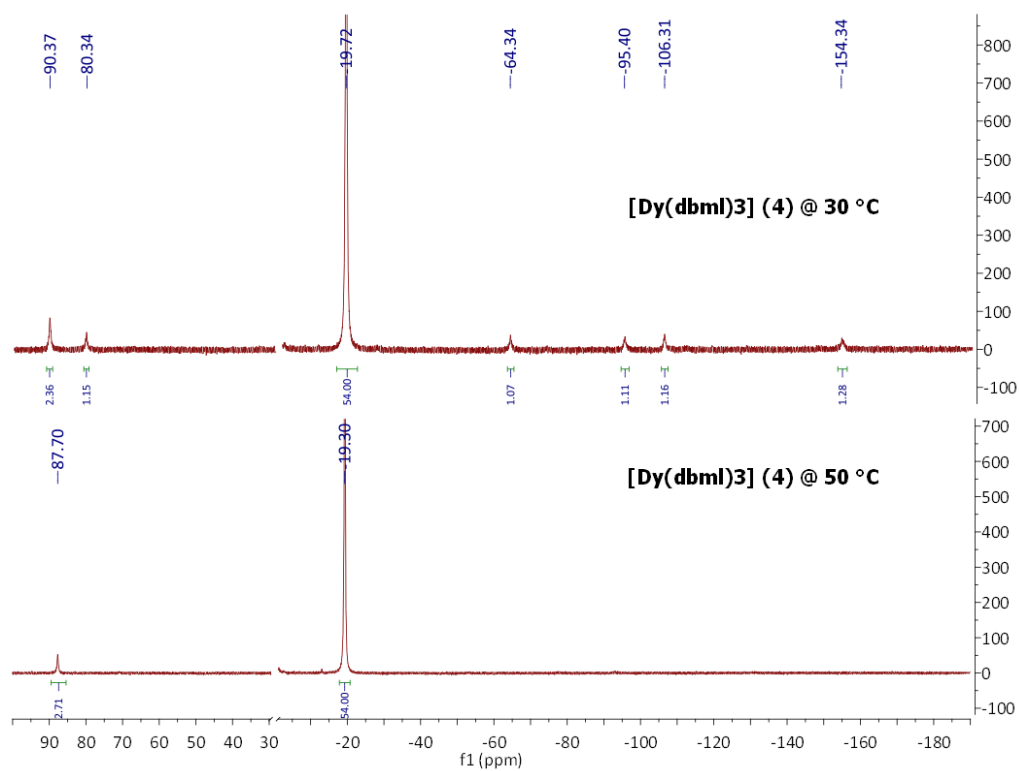
**SI 1.** Molecular structures of  $[\{\text{Dy}(\text{deml})_3\}_2]$  (**2**) in the solid state (hydrogen atoms are omitted for clarity).



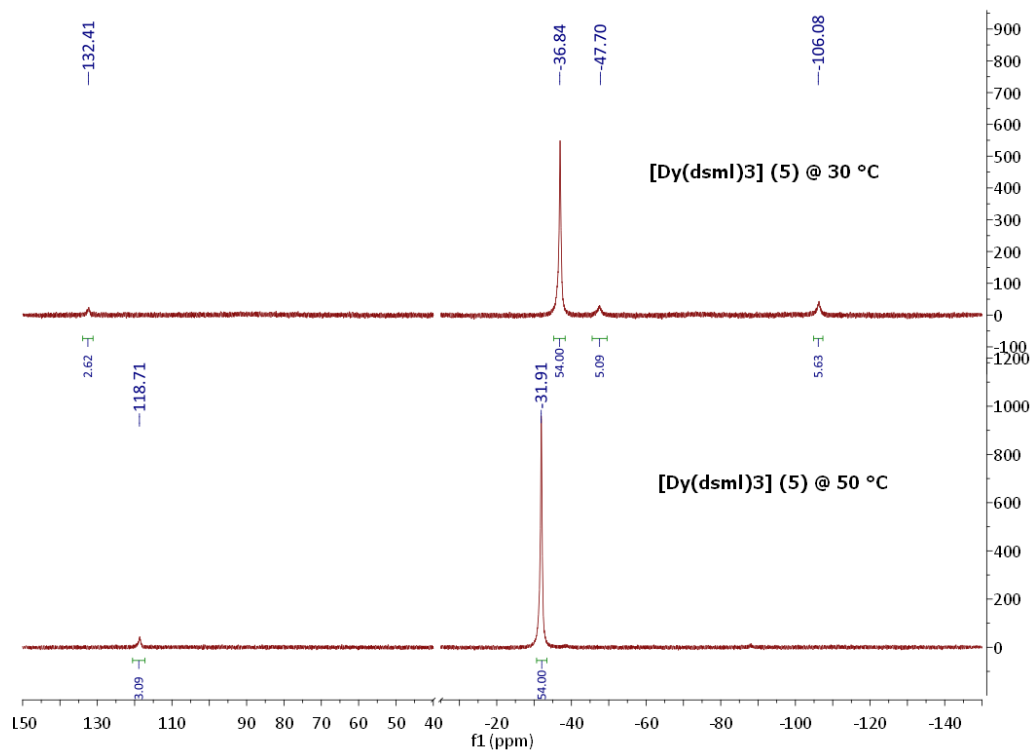
**SI 2.** Molecular structures of  $[\{\text{Dy}(\text{dpml})_3\}_2]$  (**3**) in the solid state (hydrogen atoms are omitted for clarity).



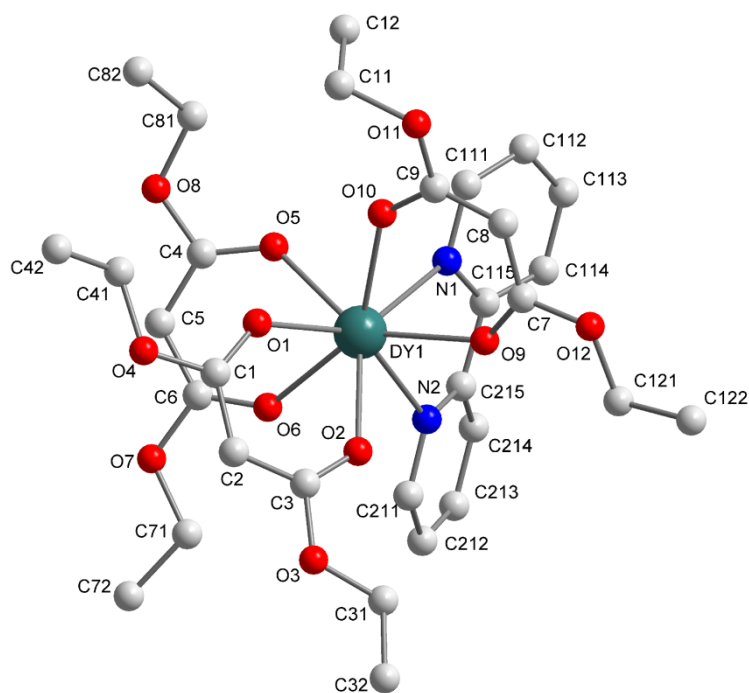
**SI 3.** Molecular structures of  $[\{\text{Dy}(\text{dbml})_3\}_2]$  (**4**) in the solid state (hydrogen atoms are omitted for clarity).



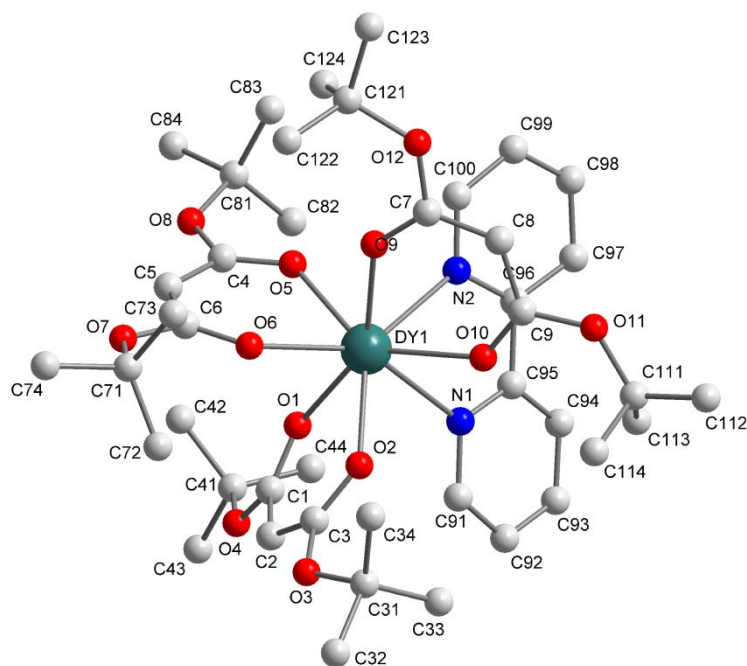
**SI 4.**  $^1\text{H}$ -NMR spectra of  $[\{\text{Dy}(\text{dbml})_3\}_2]$  (**4**) at 30 °C and 50 °C, respectively (250 MHz, toluene- $d_8$ ).



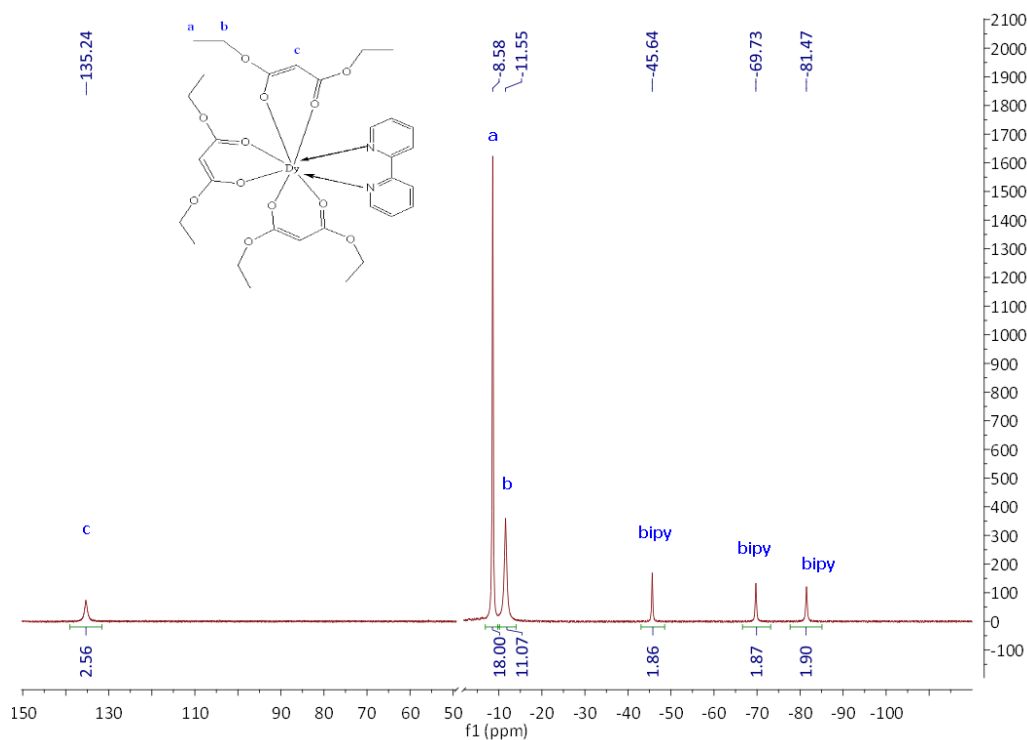
**SI 5.** <sup>1</sup>H-NMR spectra of  $[Dy(dsm1)_3]$  (**5**) at 30 °C and 50 °C, respectively (250 MHz, toluene-d<sub>8</sub>).



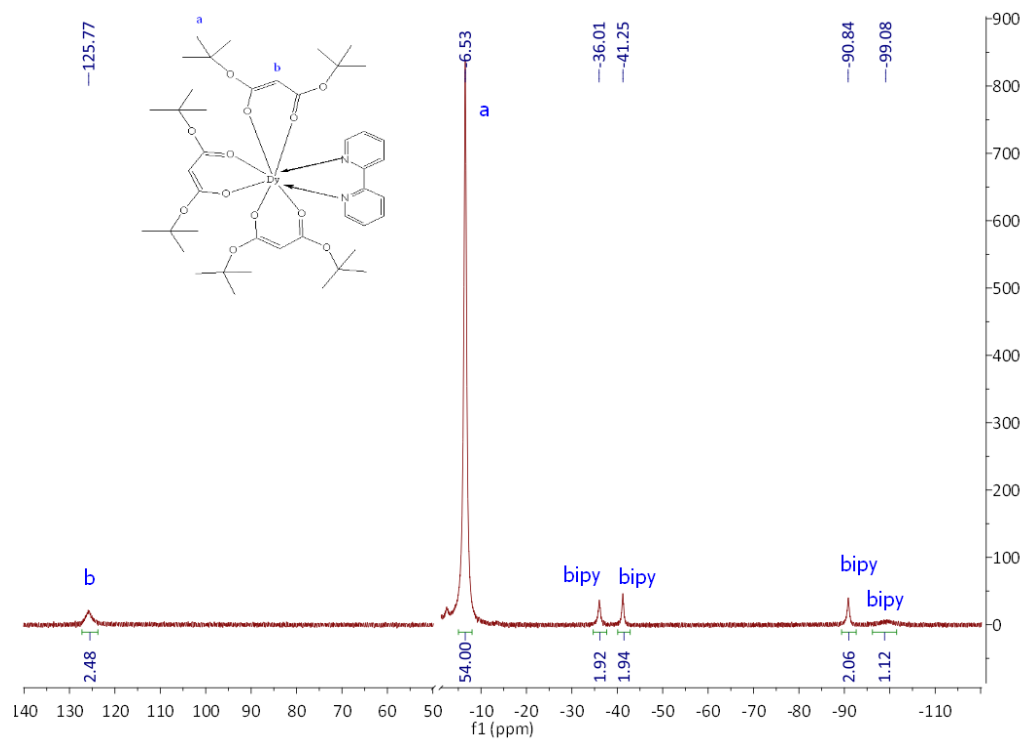
**SI 6.** Molecular structures of  $[Dy(dem1)_3bipy]$  (**6**) in the solid state (hydrogen atoms are omitted for clarity).



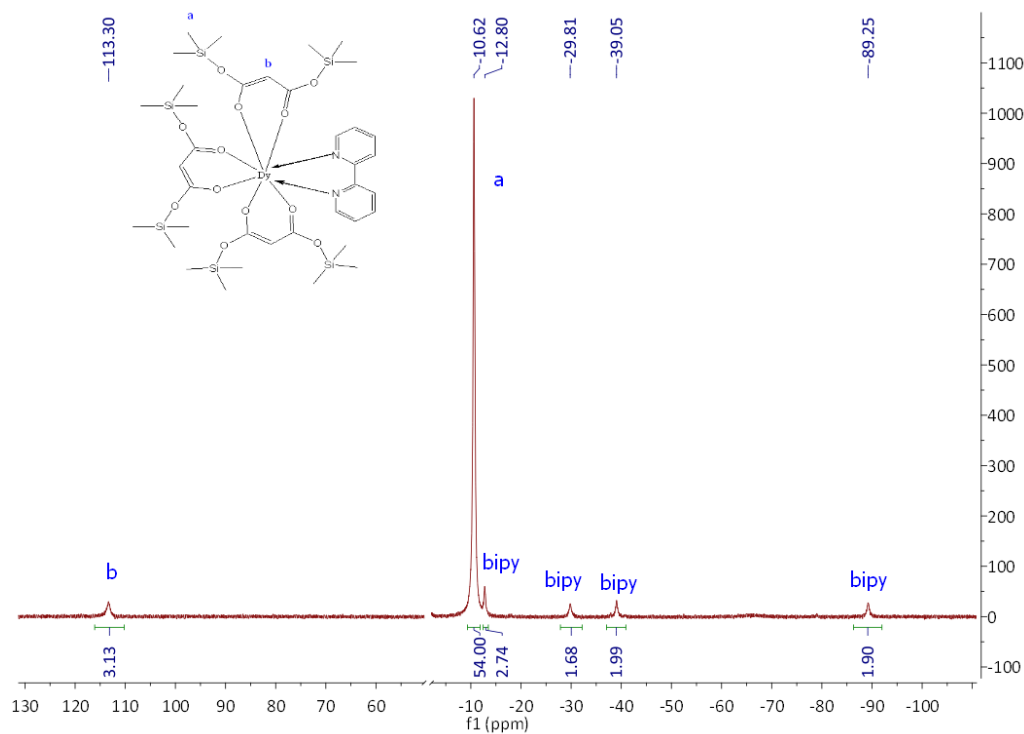
**SI 7.** Molecular structures of  $[\text{Dy}(\text{dbml})_3\text{bipy}]$  (**7**) in the solid state (hydrogen atoms are omitted for clarity).



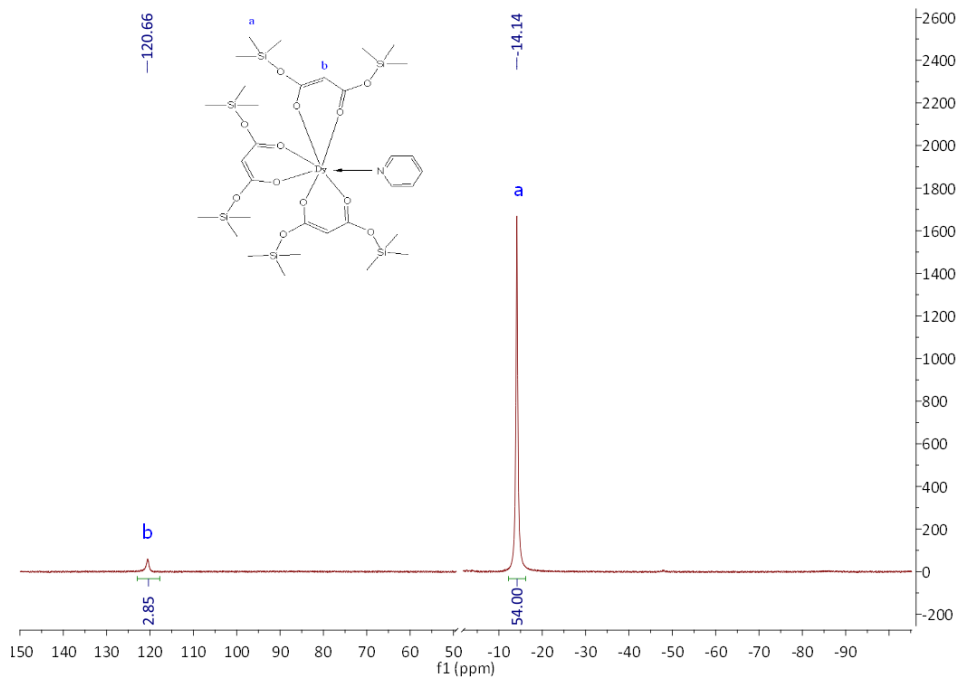
**SI 8.**  $^1\text{H}$ -NMR spectra of  $[\text{Dy}(\text{deml})_3\text{bipy}]$  (**6**) (250 MHz, toluene- $d_8$ , RT).



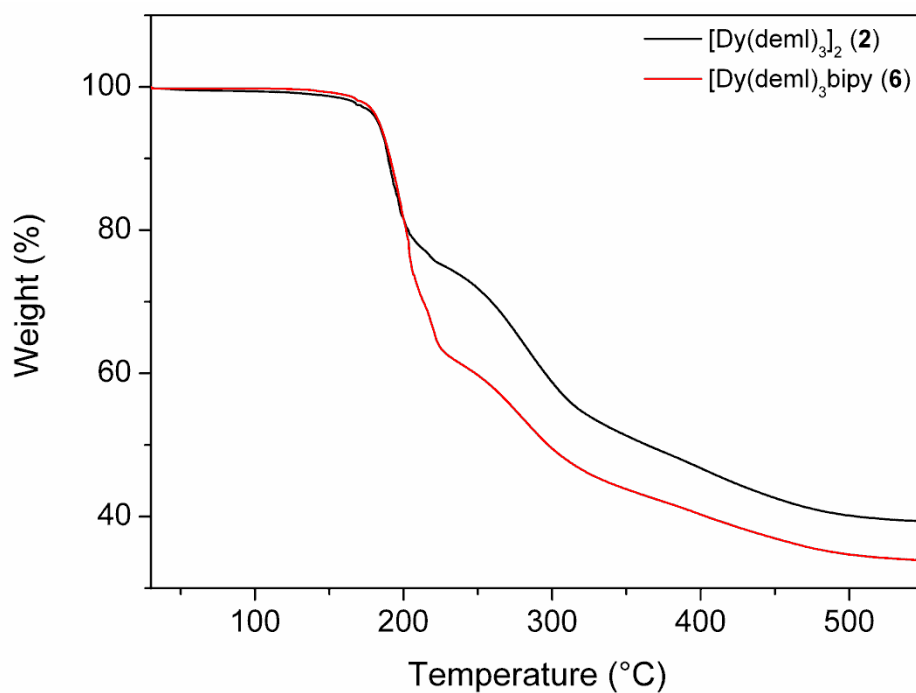
SI 9. <sup>1</sup>H-NMR spectra of [Dy(dbml)<sub>3</sub>bipy] (7) (250 MHz, toluene-d<sub>8</sub>, RT).



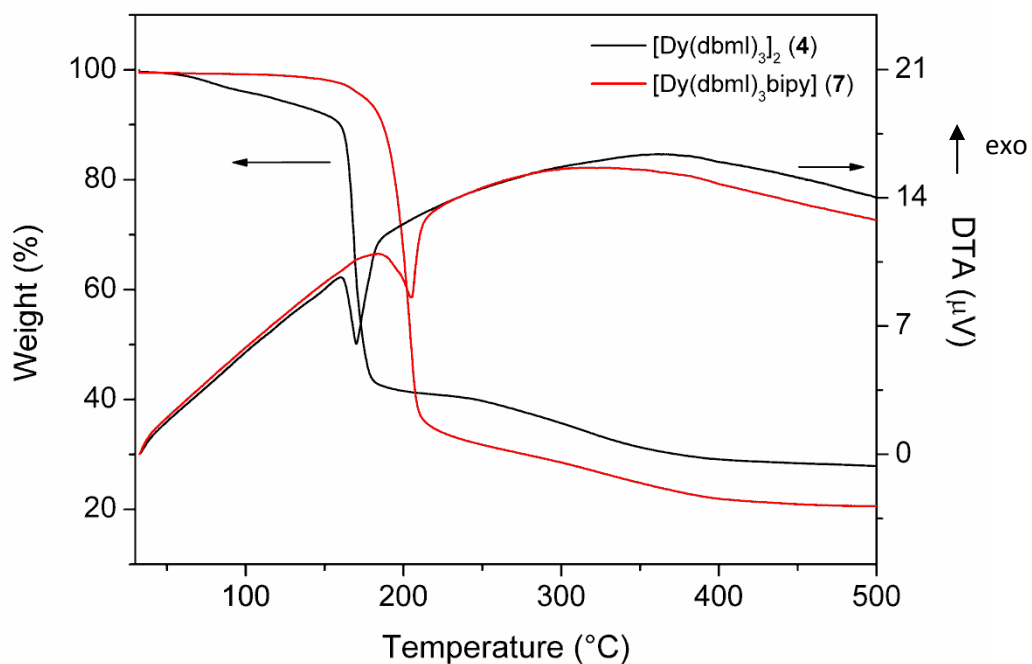
SI 10. <sup>1</sup>H-NMR spectra of [Dy(dsml)<sub>3</sub>bipy] (8) (250 MHz, toluene-d<sub>8</sub>, RT).



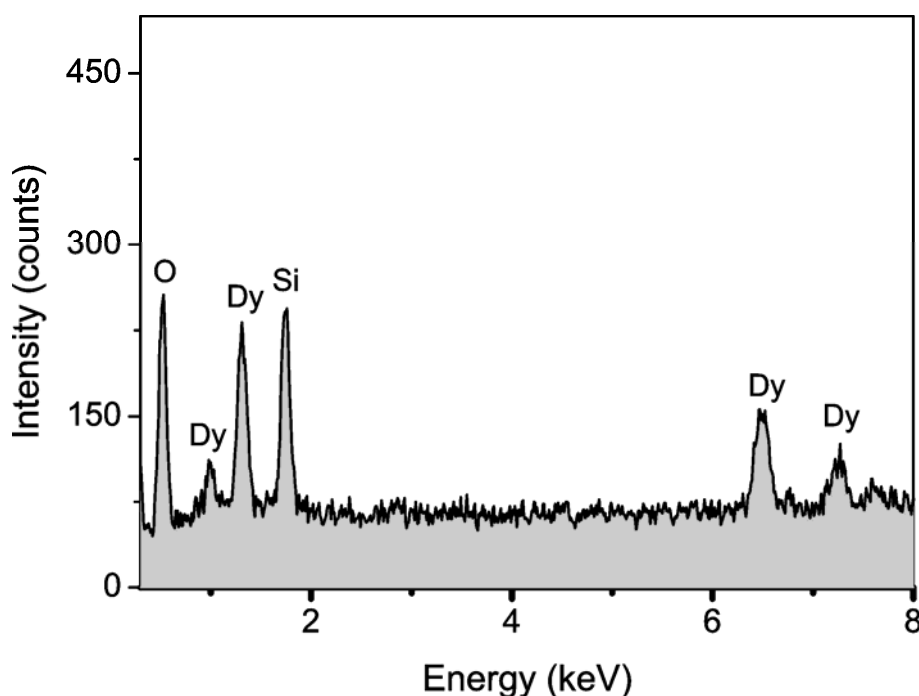
**SI 11.** <sup>1</sup>H-NMR spectra of [Dy(dsml)<sub>3</sub>py] (**9**) (250 MHz, toluene-d<sub>8</sub>, RT).



**SI 12.** TGA curves of compounds **2** and **6** (heating rate = 5 °C/min; N<sub>2</sub> flow = 300 ml/min).



**SI 13.** TGA/DTA curves of compounds **4** and **7** (heating rate = 5 °C/min; N<sub>2</sub> flow = 300 ml/min). The DTA peaks at 165 °C and 205 °C correspond to the onset of decomposition of compounds **4** and **7**, respectively.



**SI 14.** EDX spectrum of Dy<sub>x</sub>Si<sub>y</sub>O<sub>z</sub> film deposited by LI-MOCVD at 600 °C using [Dy(dsml)<sub>3</sub>bipy] (**8**) as precursor.